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Preliminary communication

Silicon-carbon unsaturated compounds

XXIII *. Transition-metal-catalyzed formation of silenes from vinyldisilanes

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Abstract

Heating pentamethylvinyldisilane in the presence of a nickel(0) catalyst at 220 °C gave a dimer, (E)-1-[2-(pentamethyldisilanyl)ethyl]dimethylsilyl-2-(trimethylsilyl)ethene (2), via a nickel-silene complex. Similar reaction of 1-phenyl-1-vinyltetramethyldisilane and 1,1-diphenyl-1-vinyltrimethyldisilane afforded the respective dimers analogous to 2.

During the course of our investigation concerning the transition-metal-catalyzed formation of reactive silicon unsaturated compounds [1,2], we have found that treatment of vinyldisilanes with a catalytic amount of a nickel(0) complex leads to novel dimerization products, presumably via a nickel-silene complex, arising from rearrangement of a silyl group to the terminal carbon of a vinyl group. Thus, when 0.186 g (1.2 mmol) of pentamethylvinyldisilane (1) was heated with 50 mg (9.4×10^{-2} mmol) of tetrakis(triethylphosphine)nickel(0) in a degassed sealed glass tube at 220 °C for 30 h, (E)-1-[2-(pentamethyldisilanyl)ethyl]dimethylsilyl-2-(trimethylsi-lyl)ethene (2) was obtained in 36% yield as a single isomer. No other isomers were detected by either GLC or spectroscopic analysis. Compound 2 could readily be isolated by preparative GLC. The structure of 2 was confirmed by IR, mass, and ¹H

and ¹³C NMR spectroscopic analysis *. The proton coupling constants (J 22 Hz) at δ 6.54 and 6.62 ppm, due to olefinic protons for 2, clearly indicates that 2 must have the (E)-configuration. That the nickel catalyst plays an important role for the formation of 2 can be shown by the fact that heating 1 in the absence of the nickel catalyst under the same conditions afforded no dimerization product, but the starting 1 was recovered unchanged.

It was shown that the present nickel-catalyzed dimerization is a general reaction for vinyldisilanes. Thus, treatment of 1-phenyl-1-vinyltetramethyldisilane (3) and 1,1-diphenyl-1-vinyltrimethyldisilane (5) with a nickel(0) catalyst under the same conditions gave (E)-1-[2-(1-phenyltetramethyldisilanyl)ethyl]methylphenylsilyl-2-(trimethylsilyl)ethene (4) and (E)-1-[2-(1,1-diphenyltrimethyldisilanyl)ethyl]diphenylsilyl-2-(trimethylsilyl)ethene (6) in 45 and 44% yields, respectively. The structures of 4 * and 6 ** were confirmed by mass, IR, and ¹H and ¹³C NMR spectroscopic analysis.

In order to establish the configuration of 4 and 6, we prepared these compounds by an independent route. Thus, addition of [2-(1-phenyltetramethyldisilanyl)ethyl]methylphenylsilane to ethynyltrimethylsilane in the presence of a catalytic amountof chloroplatinic acid gave a hydrosilylation product in 90% yield, while similarreaction of <math>[2-(1,1-diphenyltrimethyldisilanyl)ethyl]diphenylsilane with ethynyltrimethylsilane afforded an adduct in 50% yield. All spectral data obtained for theseproducts were identical with those of 4 and 6, respectively. Since the addition of anSi-H bond to a triple bond proceeds in a*cis*fashion, the resulting hydrosilylationproducts should have the <math>(E)-configuration [3].

Scheme 1 illustrates a possible mechanistic interpretation for the formation of the dimerization products. The mechanism involves the nickel-catalyzed isomerization of the vinyldisilane to a silene-nickel complex (A), followed by C-H activation by the nickel atom leading to π -silapropenyl complex (B). The regiospecific addition of the nickel-hydrogen bond across the carbon-carbon double bond of the coordinated vinyldisilane, followed by reductive elimination gives the dimer. On steric grounds, the (E)-configuration is more favorable than the (Z)-configuration.

Similar reaction using vinylmonosilanes, however, afforded no dimerization products; heating a mixture of dimethylphenylvinylsilane and a 5 mole% of the

^{*} Compound 2: Mass m/e 243($M^+ - 73$); IR 1050, 1130, 1170, 1435, 1405 cm⁻¹; ¹H NMR (ppm in CDCl₃) 0.02(s, 6H, Me₂Si), 0.05(s, 6H, Me₂Si), 0.06(s, 9H, Me₃Si), 0.07(s, 9H, Me₃Si), 0.47(s, 4H, CH₂CH₂), 6.54(d, 1H, HC=C, J 22 Hz), 6.62(d, 1H, HC=C, J 22 Hz); ¹³C NMR (ppm in CDCl₃) -4.68(Me₃Si), -4.00(Me₃Si), -1.88 (Me₂Si), -1.59(Me₂Si), 6.81(CH₂), 8.23(CH₂), 149.52, 151.50(olefinic carbons). Anal. Found: C, 52.96; H, 11.19. C₁₄H₃₆Si₄ calcd.: C, 53.16; H, 11.39%.

 ^{**} Compound 4: Mass m/e 440(M⁺); IR 1010, 1050, 1105, 1130, 1170, 1243, 1405 cm⁻¹; ¹H NMR (ppm in CDCl₃) 0.06(s, 9H, Me₃Si), 0.09(s, 9H, Me₃Si), 0.33(s, 3H, MeSi), 0.34(s, 3H, MeSi), 0.80(s, 4H, CH₂CH₂), 6.70(s, 2H, olefinic protons), 7.3-7.5 (m, 10H, phenyl ring protons); ¹³C NMR (ppm in CDCl₃) - 6.72(MeSi), -5.57(MeSi), -1.68(Me₃Si), -1.59(Me₃Si), 5.49(CH₂), 7.04(CH₂), 127.70, 127.72, 128.28, 128.89, 134.09, 134.21, 137.73, 138.50(phenyl ring carbons), 146.58, 154.00 (olefinic carbons). Anal. Found: C, 65.39; H, 9.22. C₂₄H₄₀Si₄ calcd.: C, 65.45; H, 9.09%.

 ^{***} Compound 6: Mass m/e 549(M⁺ - 15); IR 1010, 1050, 1103, 1130, 1170, 1245, 1405, 1425, 1490 cm⁻¹; ¹H NMR (ppm in CDCl₃) 0.11(s, 9H, Me₃Si), 0.16(s, 9H, Me₃Si), 1.17(s, 4H, CH₂CH₂), 6.69(d, 1H, HC=C, J 23 Hz), 6.98(d, 1H, HC=C, J 23 Hz), 7.2-8.0(m, 20H, phenyl ring protons); ¹³C NMR (ppm in CDCl₃) -1.59(Me₃Si), -0.96 (Me₃Si), 5.14(CH₂), 6.40(CH₂), 127.80, 128.68, 129.22, 134.62, 135.31, 135.69, 136.34(phenyl ring carbons), 143.99, 156.82(olefinic carbons). Anal. Found: C, 72.25; H, 7.80. C₃₄H₄₄Si₄ calcd.: C, 72.34; H, 7.80%.



Scheine 1.

nickel(0) complex under the same conditions gave no product. The starting vinylsilane was recovered unchanged.

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